Applauding Students Who Earned GPAs of 4.0 Fall Quarter at NTID and RIT

January 1, 1998

Applauding Students Who Earned GPAs of 4.0 Fall Quarter at NTID and RIT 4.0 GPAs: Nearly 30 NTID students earned a grade point average of 4.0 for the fall 1997 quarter at RIT. "Students who earn a 4.0 achieve an incredible accomplishment," says Dr. James DeCaro, dean of NTID. "We are very proud of these students. They are among the most talented and motivated members of the student body of our college."

Listed below are the high academic achievers:

Brian K. Abshier, 3rd year applied accounting, Pembroke, Massachusetts

Gavin A. Ballow, 1st year architectural technology, St. Louis, Missouri

Edward Henry Bart IV, 3rd year imaging technology, Arlington, Texas

Kevin J. Bartsch, 2nd year electronic publishing & printing technology, Sloan, New York

Robert W. Bedrosian, 2nd year applied computer technology, Waltham, Massachusetts

Sara Calatrava, 1st year imaging technology, Boca Raton, Florida

Sharon A. Cooke, 2nd year educational interpreting, Rochester, New York

Elizabeth R. Dynda, 1st year applied accounting, Peoria, Illinois

Diane P. Gutierrez, 1st year electronic printing & printing technology, Pittsford, New York

Christine E. Hahnenstein, 2nd year educational interpreting, Painted Post, New York

Daria Ann Hockenberry, 2nd year educational interpreting, Rochester, New York

Shawn S. Horvath, 3rd year business technologies, Phillipsburg, New Jersey

Richard D. Humphreys, 6th year woodworking and furniture design, Rochester, New York

Christian Raul Johnson, 3rd year applied computer technology, La Paz, Bolivia

Bridget A. Klein, 1st year career exploration, Boscobel, Wisconsin

Charles J. Lombardi, 3rd year applied computer technology, Howell, New Jersey

Brett S. Mellon, 3rd year applied computer technology, Highland Falls, New York

Barbara A. Paine, 2nd year educational interpreting, Rochester, New York

Meghan L. Rainone, 4th year criminal justice, Marlton, New Jersey

Victor D. Ramos, 1st year computer integrated machining technology, Staten Island, New York

Nicole J. Ribis, 1st year educational interpreting, Webster, New York

Wan San See, 1st year information technology, Singapore, Malaysia

Amber L. Stanton, 1st year applied art and computer graphics, Penn Hills, Pennsylvania

Kieistiaa M. Thorp, 3rd year ophthalmic optical finishing technology, Boonville, New York

Jeremy D. Valent, 1st year computer integrated machining technology, Bridgeville, Pennsylvania

Candice M. Van Wart, 1st year undeclared, Buffalo, New York

Megan R. Walsh, 1st year imaging technology, San Diego, California